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APPLICATION NO.	FI	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/942,823	(08/30/2001	James M. Leas	FIS920010082US1	FIS920010082US1 9997	
30743	7590	07/11/2005		EXAM	INER	
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SUITE 340				ART UNIT	PAPER NUMBER	
RESTON VA 20100				2/20		

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Please find below and/or attached an Office communication concerning this application or proceeding.

	eN						
	Application No.	Applicant(s)					
	09/942,823	LEAS, JAMES M.					
Office Action Summary	Examiner	Art Unit					
	Hanh Phan	2638					
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).					
Status							
 1) Responsive to communication(s) filed on 30 At 2a) This action is FINAL. 2b) This 3) Since this application is in condition for allowar closed in accordance with the practice under E 	action is non-final. nce except for formal matters, pro						
Disposition of Claims							
4) ☐ Claim(s) 1-42 is/are pending in the application. 4a) Of the above claim(s) is/are withdray 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-42 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	vn from consideration.						
Application Papers							
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) access applicant may not request that any objection to the conference of the c	epted or b) objected to by the Idrawing(s) be held in abeyance. See ion is required if the drawing(s) is obj	e 37 CFR 1.85(a). lected to. See 37 CFR 1.121(d).					
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority application from the International Bureau. * See the attached detailed Office action for a list	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	on No ed in this National Stage					
Attachment(s)							
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal F 6) Other:						

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DETAILED ACTION

1. This Office Action is responsive to the Amendment filed on 02/14/2005.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-42 are rejected under 35 U.S.C. 103(a) as being unpatentable over Rao (US Patent No. 5,889,903 cited by applicant) in view of Presting et al (US Patent No. 6,043,517).

Regarding claims 1, 18 and 30, referring to Figures 3, 5 and 6, Rao discloses a method for providing an optical signal (i.e., laser pulse 505, Fig. 5) to a semiconductor (i.e., a semiconductor 513, Fig. 5), comprising the steps of:

providing a semiconductor substrate (i.e., semiconductor substrate 513, Fig. 5) having a first surface (i.e., front side, Fig. 5) and a second surface (i.e., back side 511, Fig. 5) opposite the first surface, a semiconductor of a semi-conducting material (i.e., semiconductor silicon 513, Fig. 5);

forming a device (i.e., P-N junction 515, Fig. 5) in the semiconductor layer to collect carriers generated by the optical signal; and

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directing the optical signal (laser pulse 505, Fig. 5) at the second surface (back side 511, Fig. 5) and is absorbed by the semiconductor (col. 5, lines 49-67 and col. 6, lines 1-42).

Rao differs from claims 1, 18 and 30 in that he fails to teach a semiconductor substrate having a first semiconductor layer of a first semiconducting material adjacent the first surface, the first semiconductor layer on a second semiconductor of a second semiconducting material, the first semiconducting material having a higher absorption coefficient than the second semiconducting material when both the first semiconducting material and the second semiconducting material are undoped and forming a device in the first semiconductor layer to collect carriers generated by the optical signal and the portion of the optical signal can pass through the second semiconductor is absorbed by the first semiconductor material in the first semiconductor layer. However, Presting in US Patent No. 6,043,517 teaches a semiconductor substrate having a first semiconductor layer of a first semiconducting material adjacent the first surface, the first semiconductor layer on a second semiconductor of a second semiconducting material, the first semiconducting material having a higher absorption coefficient than the second semiconducting material when both the first semiconducting material and the second semiconducting material are undoped and forming a device in the first semiconductor layer to collect carriers generated by the optical signal and the portion of the optical signal can pass through the second semiconductor is absorbed by the first semiconductor material in the first semiconductor layer (Figs. 1 and 2, col. 1, lines 36-64 and col. 3, lines 4-32). Therefore, it would have been obvious to one having skill in the

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art at the time the invention was made to incorporate the semiconductor substrate having a first semiconductor layer of a first semiconducting material adjacent the first surface, the first semiconductor layer on a second semiconductor of a second semiconducting material, the first semiconducting material having a higher absorption coefficient than the second semiconducting material when both the first semiconducting material and the second semiconducting material are undoped and forming a device in the first semiconductor layer to collect carriers generated by the optical signal and the portion of the optical signal can pass through the second semiconductor is absorbed by the first semiconductor material in the first semiconductor layer as taught by Presting in the system of Rao. One of ordinary skill in the art would have been motivated to do this since Presting suggests in column 1, lines 36-64 and col. 3, lines 4-32 that using such the semiconductor substrate having a first semiconductor layer of a first semiconducting material adjacent the first surface, the first semiconductor layer on a second semiconductor of a second semiconducting material, the first semiconducting material having a higher absorption coefficient than the second semiconducting material when both the first semiconducting material and the second semiconducting material are undoped and forming a device in the first semiconductor layer to collect carriers generated by the optical signal and the portion of the optical signal can pass through the second semiconductor is absorbed by the first semiconductor material in the first semiconductor layer have advantage of allowing reducing the clock skew and increasing the signal to noise ratio and the longer waved light is absorbed.

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Regarding claim 2, the combination of Rao and Presting teaches wherein the optical signal comprises an optical clocking signal (col. 5 of Rao, lines 49-53 and Figs. 1 and 2 of Presting).

Regarding claim 3, the combination of Rao and Presting teaches wherein the optical signal comprises an optical data signal (Fig. 5 of Rao and Figs. 1 and 2 of Presting).

Regarding claim 4, the combination of Rao and Presting teaches wherein the optical data signal comprises digital data for data processing, text, graphic, voice, or video (Fig. 5 of Rao).

Regarding claim 5, the combination of Rao and Presting teaches wherein the optical signal is absorbed in the first semiconductor layer for generating an electrical signal (Figs. 1 and 2 of Presting).

Regarding claims 6, 19 and 31, the combination of Rao and Presting teaches wherein the first semiconducting material comprises germanium and the second semiconducting material comprises silicon (Figs. 1 and 2 of Presting, col. 1, lines 36-64 and col. 3, lines 4-32).

Regarding claims 7, 20 and 32, the combination of Rao and Presting teaches wherein the germanium containing material comprises SiGe (col. 1 of Presting, lines 36-64 and col. 3, lines 4-32).

Regarding claim 8, the combination of Rao and Presting teaches the step of depositing a layer containing germanium, and the step of forming the device in or on the layer (col. 1 of Presting, lines 36-64 and col. 3, lines 4-32).

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Regarding claims 9, 21 and 33, the combination of Rao and Presting teaches the germanium concentration of the germanium containing layer is graded (col. 1 of Presting, lines 36-64 and col. 3, lines 4-32).

Regarding claims 10, 28 and 41, the combination of Rao and Presting teaches the first semiconducting material comprises a lower bandgap than the second semiconducting material (col. 1 of Presting, lines 36-64 and col. 3, lines 4-32).

Regarding claims 11, 29 and 42, the combination of Rao and Presting teaches wherein the first semiconducting material comprises an amorphous material or a direct bandgap material and the second semiconducting material comprises a crystalline material or an indirect bandgap material (col. 1 of Presting, lines 36-64 and col. 3, lines 4-32).

Regarding claims 12 and 35, the combination of Rao and Presting teaches wherein the energy of the optical signal is in the range from 0.66eV to 1.12eV (col. 5 of Rao, lines 5-8 and col. 1 of Presting, lines 36-64 and col. 3, lines 4-32).

Regarding claims 13, 24 and 36, the combination of Rao and Presting teaches wherein the device is selected from a P-N diode, a PIN diode, a Schottky diode and a transistor (col. 1 of Presting, lines 36-64 and col. 3, lines 4-32).

Regarding claims 14, 23, 25-27, 34 and 37, the combination of Rao and Presting teaches wherein the substrate is an integrated circuit chip and wherein a plurality of the devices are distributed around the integrated circuit chip for simultaneously receiving the optical signal (Fig. 5 of Rao and Figs. 1 and 2 Presting).

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Regarding claims 15 and 38, the combination of Rao and Presting teaches wherein the optical signal comprises an optical clocking signal, and wherein the integrated circuit chip further comprises devices or circuits that use the clocking signal when it is converted to an electrical clocking signal (Figs. 4 and 5 of Rao and Figs. 1 and 2 of Presting).

Regarding claims 16, 17, 39 and 40, the combination of Rao and Presting teaches further comprising a plurality of integrated circuit chips, wherein each of the integrated circuit chips comprise at least one of the devices and wherein each of the integrated circuit chips are configured to receive the optical signal (Fig. 5 of Rao and Figs. 1 and 2 of Presting).

Regarding claim 22, the combination of Rao and Presting teaches the germanium containing layer has a thickness ranging from about $0.1\mu m$ to about $1\mu m$ col. 1 of Presting, lines 36-64 and col. 3, lines 4-32).

Response to Arguments

4. Applicant's arguments with respect to claims 1-42 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hanh Phan whose telephone number is (571)272-3035.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Kenneth Vanderpuye, can be reached on (571)272-3078. The fax phone number for the organization where this application or proceeding is assigned is (703)872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)305-4700.

HANH PHAN PRIMARY EXAMINER